

AMENDMENTS TO THE CLAIMS

1. (Currently Amended) A method for constructing EMI shielding around a component (12) to be embedded in a circuit board, which circuit board comprises ~~includes~~ alternating conductor layers (1) and insulating layers (2), and at least a substantial portion of the component (12) is embedded inside the circuit board and around it is placed a structure (10) shielding from electromagnetic radiation, which shields against electromagnetic radiation coming from at least the direction of the circuit board, c h a r a c t e r i z e d in that the component is an optoelectronic component

-a recess (6) is formed around the embedding location of the component (12), in such a way that an insulating layer (7) is left between the embedding location of the component (12) and the recess, and in such a way that the recess is extended from the surface of the circuit board to such an insulating layer as represents the ground-reference plane (3),

-the recess (6) is filled or surfaced with an electrically conductive material (8, 9), in such a way that the material is in electrical contact with the ground-reference plane (3) and that the material essentially surrounds the component as a bezel (10) in the direction of the circuit board.

2. (Original) A method according to claim 1, c h a r a c t e r i z e d in that, when the recess (6) is formed, only the material or materials, which do not act as an electrical transmission path (2), are removed from the circuit board.

3. (Currently Amended) A method according to claim 1-~~or 2~~, characterized in that there is a ground-reference plan (3) under the entire area, in which the recess (6) is made.

4. (Currently Amended) A method according to ~~any of the above claims~~ claim 1, characterized in that, after the lining or filling of the recess, a cavity (11), which extends to the level of the ground-reference plane (3), is made for the component (12), and the component is embedded in the cavity that has been made.

5. (Currently Amended) A method according to ~~any of the above claims~~ claim 1, characterized in that the component is a semiconductor component, or a passive component, such as an integrated passive component.

6. (Currently Amended) A method according to ~~any of the above claims~~ claim 1, characterized in that the electrically conductive material (8, 9), with which the recess is surfaced or filled, is a transparent, translucent, and/or flexible material.

7. (Currently Amended) A method according to ~~any of the above claims~~ claim 1, characterized in that the electrically conductive material (8, 9), with which the recess is surfaced or filled, is a conductive polymer, or a conductive glue.

8. (Currently Amended) A method according to ~~any of the above claims~~ claim 1, characterized in that the electrically conductive material (8, 9), with which the recess is surfaced or

filled, is a metal.

9. (Currently Amended) A method according to ~~any of the above claims~~ claim 1, c h a r a c t e r i z e d in that the component (12) is electrically connected to the conductor layer (1) located below the ground-reference plane.

10. (Currently Amended) A method according to ~~any of the above claims~~ claim 1, c h a r a c t e r r i z e d in that, at the embedding location of the component (12), a continuous or discontinuous metal layer (5) is left on the ground-reference plane, and the component is connected electrically to the metal layer.

11. (Original) A method according to claim 10, c h a r a c t e r i z e d in that the connected is made with the aid of solder or a conductive polymer or glue (13).

12. (Currently Amended) A method according to claim 10 ~~or 11~~, c h a r a c t e r i z e d in that the metal layer (5) is connected electrically to the conductor layer (1) located below the ground-reference place (3).

13. (Original) A method according to claim 12, c h a r a c t e r i z e d in that the conductor layer (1) below the ground-reference plane (3) is manufactured only after an electrical contact has been made between the metal layer (5) and the conductor layer (1).

14. (Currently Amended) A method according to ~~any of the above claims~~ claim 1, c h a r a c t e r i z e d in that the component (12) is connected electrically to a conductor layer (1) located above the ground-reference plane.

15. (Currently Amended) A circuit board, which comprises ~~includes~~

- a component (12), at least a substantial portion of which is embedded inside the circuit board, and

- a structure (10) built around the component (12), which shields against electromagnetic radiation coming from at least the direction of the circuit board,

c h a r a c t e r i z e d in that the component is an optoelectronic component that the structure (10) comprises a recess (6) around the embedding location of the component, extending to the ground-reference plane (3), and an insulating layer between the recess (6) and the cavity (11) made at the embedding location of the component, which recess essentially surrounds the component (12) in the direction of the circuit board (12), and which recess (6) is filled with an electrically conductive material (8, 9), in such a way that the material is in electrical contact with the ground-reference plane (3).

16. (Original) A circuit board according to claim 15, c h a r a c t e r i z e d in that the circuit board and the bezel (10) built into it shielding against electromagnetic radiation are flexible.

17. (Currently Amended) A circuit board according to claim 15 ~~or 16~~, c h a r a c t e r i z e d in that the recess (6) is filled with a conductive polymer or a conductive glue.

18. (Currently Amended) A circuit board according to ~~any of claims 15—17~~ claim 15, c h a r a c t e r i z e d in that the component (12) is electrically connected to a conductor layer (1) located below the ground-reference plane (3).

19. (Currently Amended) A circuit board according to ~~any of claims 15—18~~ claim 15, c h a r a c t e r i z e d in that, at the embedding location of the component (12), there is, on the level of the ground-reference plane, a continuous or discontinuous metal layer (5), to which the component is electrically connected.

20. (Original) A circuit board according to claim 19, c h a r a c t e r i z e d in that the component (12) is connected to the metal layer (5) with the aid of a conductive glue or conductive polymer (13).

21. (Currently Amended) A circuit board according to ~~any of claims 15—20~~ claim 15, c h a r a c t e r i z e d in that the metal layer (5) is connected electrically to the conductor layer (1) located below the ground-reference plane (3).

22. (Currently Amended) A circuit board according to ~~any of claims 15—21~~ claim 15, c h a r a c t e r i z e d in that the component (12) is connected electrically to the conductor layer (1) located above the ground-reference plane (3).